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Correction: Mitigating substrate effects of van der Waals semiconductors using perfluoropolyether self-assembled monolayers

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Correction for 'Mitigating substrate effects of van der Waals semiconductors using perfluoropolyether self-assembled monolayers' by Dae Young Park *et al.*, *Nanoscale*, 2024, **16**, 10779–10788, https://doi.org/10.1039/D4NR00061G.

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The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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